

# **Analysis of Superconducting Thin Films in a Modern FIB/SEM Dual-Beam Instrument** L. Grünewald<sup>1</sup>, D. Nerz<sup>1</sup>, M. Langer<sup>2</sup>, S. Meyer<sup>2</sup>, N. Beisig<sup>2</sup>, P. Cayado<sup>2</sup>, R. Popov<sup>2</sup>, J. Hänisch<sup>2</sup>, B. Holzapfel<sup>2</sup>, D. Gerthsen<sup>1</sup>

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## Introduction

- Epitaxially grown superconducting thin films are of interest for fundamental research and applications (e.g. coated conductors<sup>1</sup>)
- nm-sized structural defects desirable for flux pinning<sup>2</sup>
  - Increased critical current density
  - Aim: Control of defect formation during film fabrication
- Combined focused-ion-beam/scanning electron microscope (FIB/SEM) instrument for high-throughput microstructural and chemical analysis

## **Materials & Methods**

• Thin films:

Ba(Fe,Co)<sub>2</sub>As<sub>2</sub> GdBa<sub>2</sub>Cu<sub>2</sub>O<sub>7-8</sub>

(~50 nm) on CaF<sub>2</sub> substrate<sup>3</sup> (~350 nm) on MgO substrate

- FIB/SEM: Thermo Scientific Helios G4 FX
- Dedicated STEM holder for *in-situ* lift-out and subsequent STEM-in-SEM imaging (bright-field (BF) and (high-angle) annular dark-field (HAADF)) without breaking microscope vacuum
- Energy-dispersive x-ray spectroscopy (EDXS): Bruker X-Flash 6|60



### Summary



Modern FIB/SEM instruments  $\rightarrow$  high-throughput structural and chemical analyses down to nm-scale

**Reactive materials** examined without exposure to ambient atmosphere

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